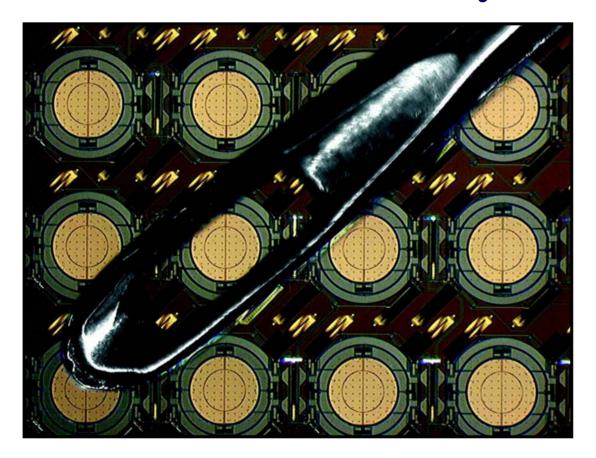
Nanomaterials

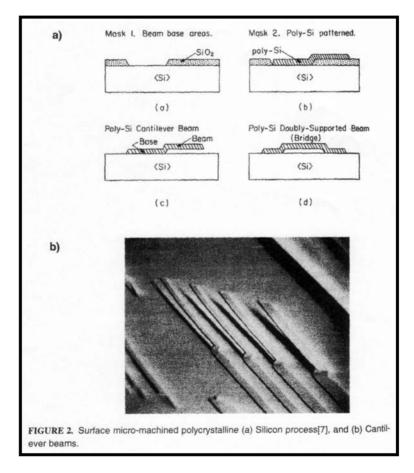
Lecture 18: Nanoelectromechanical Systems

Nanoelectromechanical Systems



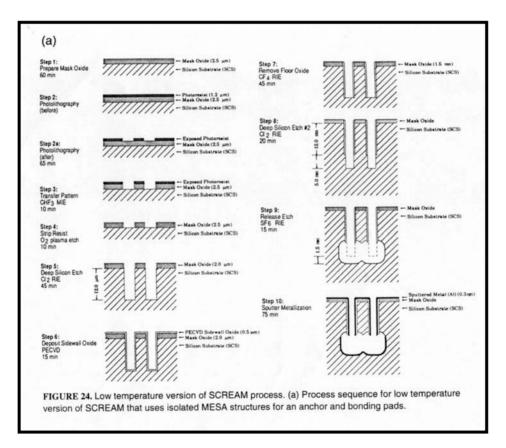
H. G. Craighead, Science, 290, 1532 (2000).

Poly-Silicon Thin Film Processing



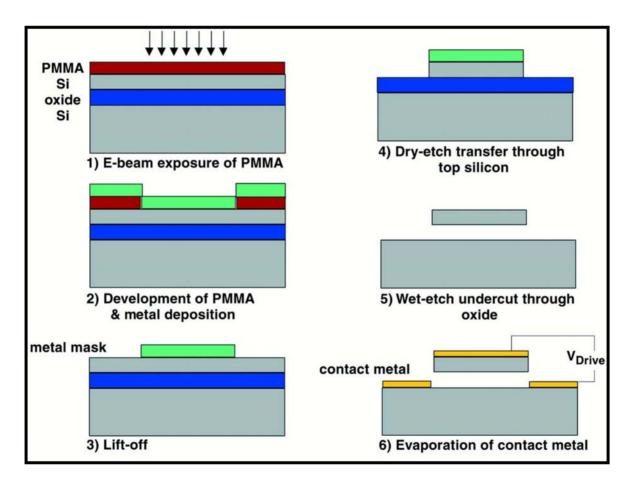
→ Problems with uniformity of thin films and built-in strain

Single Crystal Reactive Etching and Metallization (SCREAM)



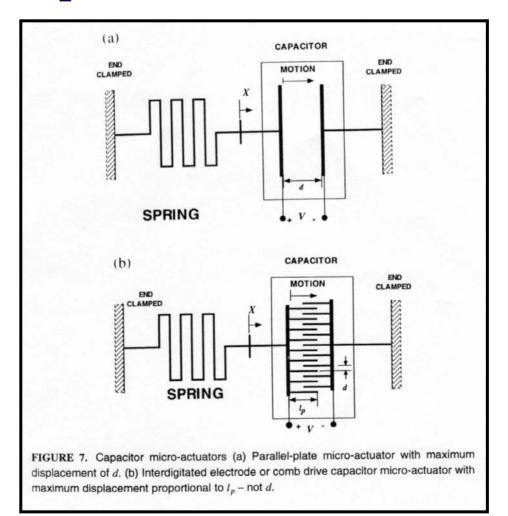
Suspended single crystal silicon $\rightarrow E \sim 130$ GPa (comparable to steel)

MEMS Fabrication using Silicon-on-Insulator Substrates



H. G. Craighead, Science, 290, 1532 (2000).

Capacitive Micro-Actuator



Capacitive Micro-Actuator

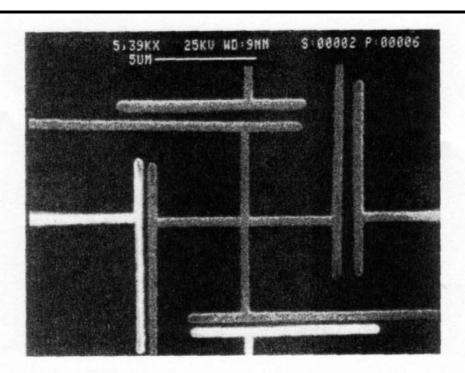


FIGURE 8. SEM micrograph of four parallel-plate capacitors suspended by springs. The cross in the center has been displaced downward and to the left by actuation of two sets of plates – white plates are negative. The single crystal silicon plates are 10 μ m \times 200 nm.

Capacitive Displacement Sensor

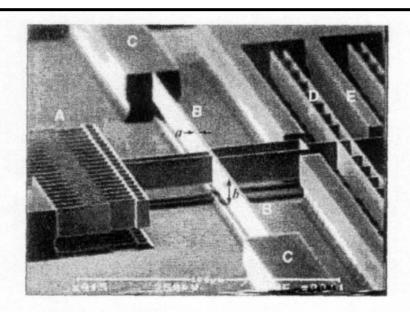
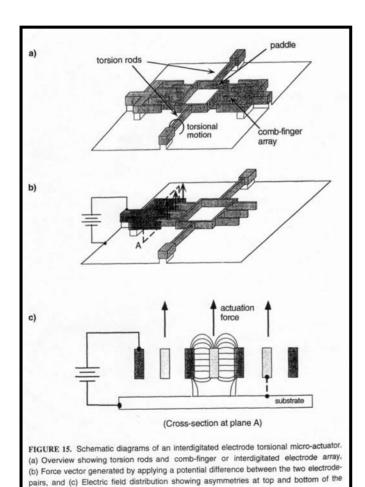


FIGURE 9. A high aspect-ratio (b/a) single crystal silicon device made using SCREAM processes[63]. [A]-Interdigitated electrode micro-actuator that moves the structure to the left when a voltage is applied to the two sets of electrodes. [B]-Suspended spring with supports-[C]; [D]-Moving suspended plate of a parallel-plate capacitor attached to the spring and a fixed plate [E]. The parallel-plate capacitor is used to sense displacement.

Torsional Micro-Actuator



electrodes[55].

Asymmetry in electric field lines actuate vertical motion

Torsional Micro-Actuator

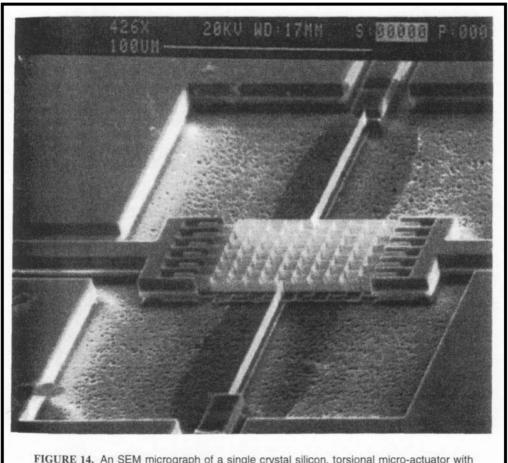
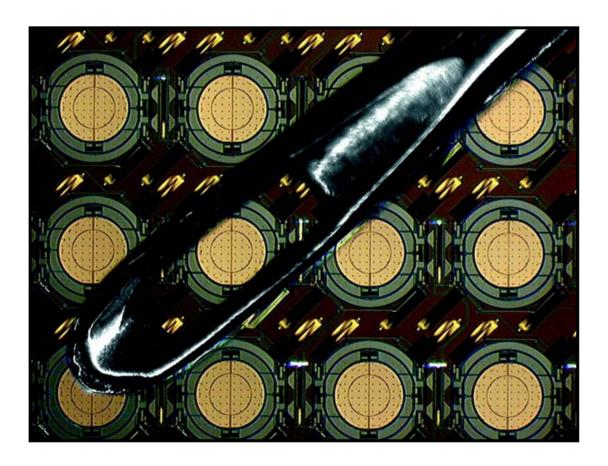


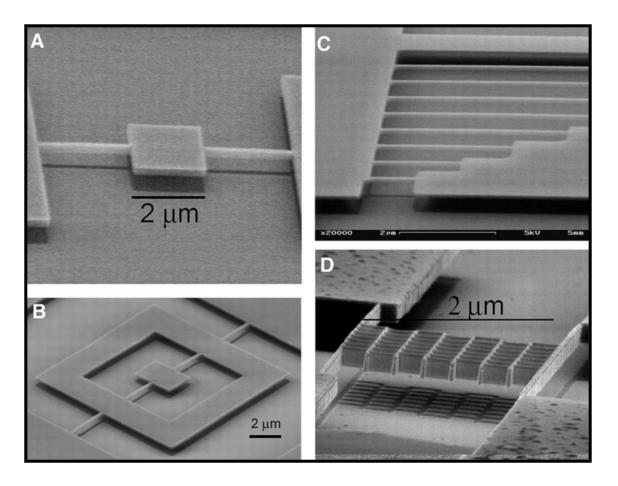
FIGURE 14. An SEM micrograph of a single crystal silicon, torsional micro-actuator with interdigitated electrode drives[55].

Lucent Technologies Mirror Array



H. G. Craighead, Science, 290, 1532 (2000).

Silicon Micromirrors and Nanowires



H. G. Craighead, Science, 290, 1532 (2000).

Resonance Frequency of NEMS Structures

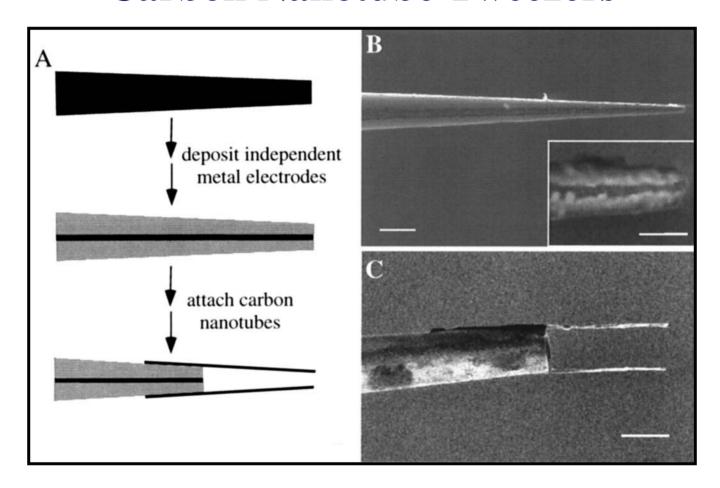
Resonant frequency of a doubly clamped beam:

$$f_0 = \frac{(4.730)^2}{2\pi} \frac{1}{l^2} \sqrt{\frac{EI}{\rho A}}$$

Note: 2 µm long, 50 nm wide wires have $f_0 \sim 400$ MHz

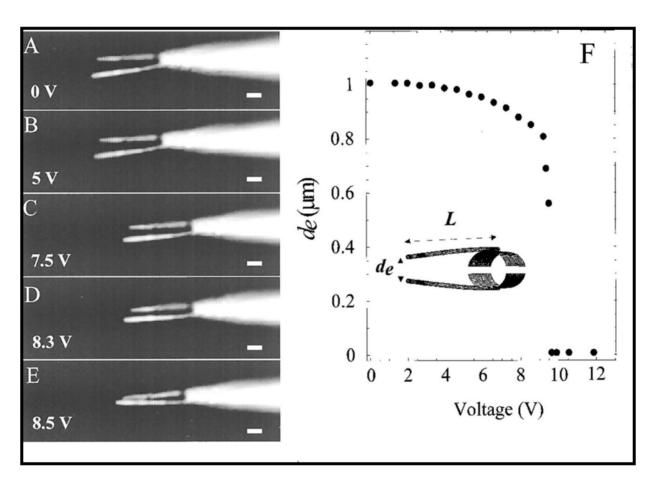
→ Resonance frequency inversely scales with size

Carbon Nanotube Tweezers



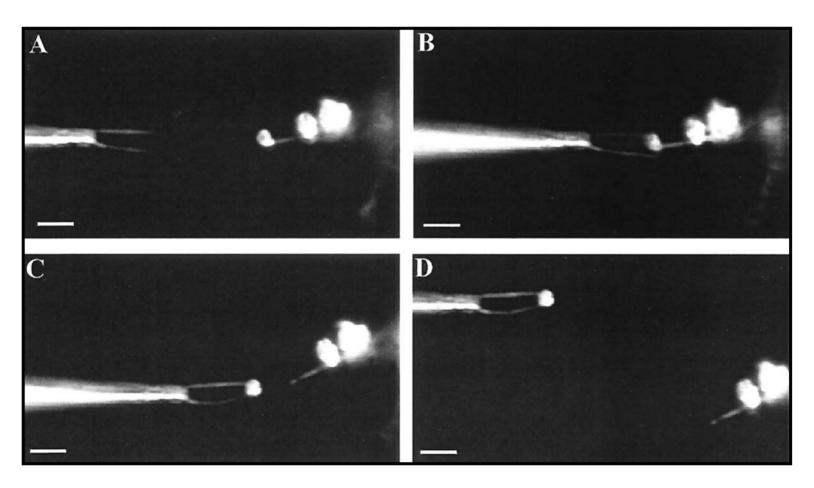
P. Kim and C. M. Lieber, *Science*, **286**, 2148 (1999).

Carbon Nanotube Tweezers



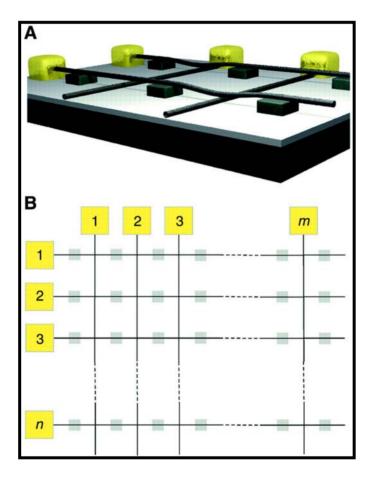
P. Kim and C. M. Lieber, *Science*, **286**, 2148 (1999).

Carbon Nanotube Tweezers



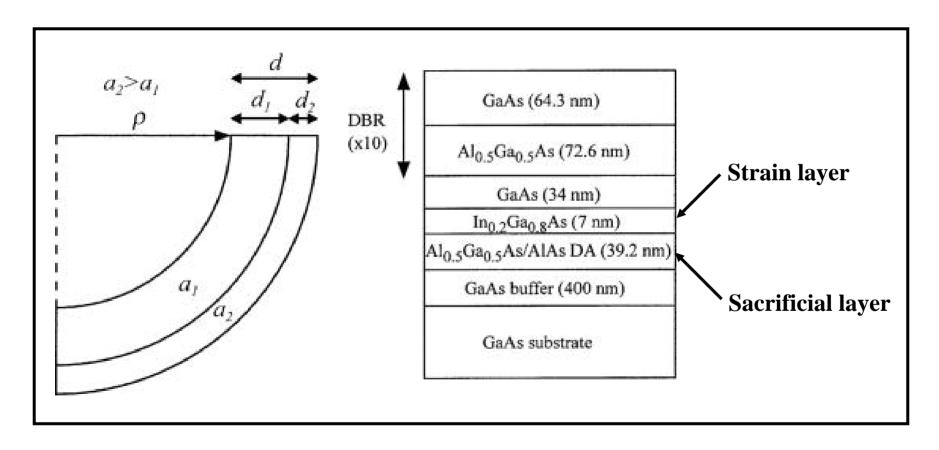
P. Kim and C. M. Lieber, *Science*, **286**, 2148 (1999).

Nonvolatile Carbon Nanotube Memory



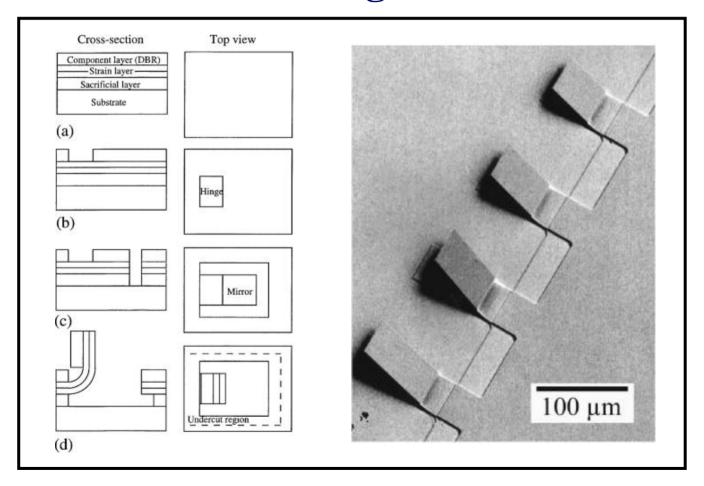
T. Rueckes, et al., Science, 289, 94 (2000).

Strain-driven Positioning of MEMS Structures



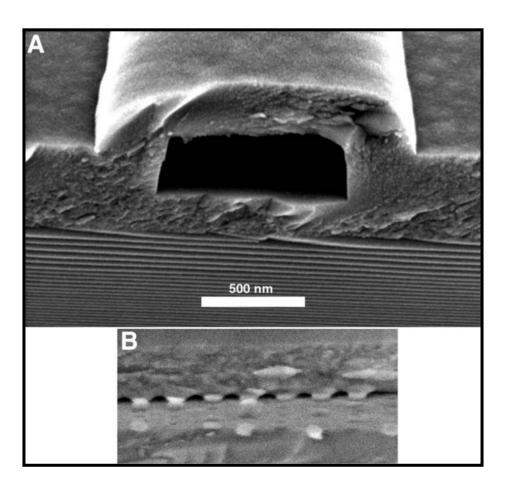
P. O. Vacaro, et al., Appl. Phys. Lett., 78, 2852 (2001).

Strain-driven Positioning of MEMS Structures

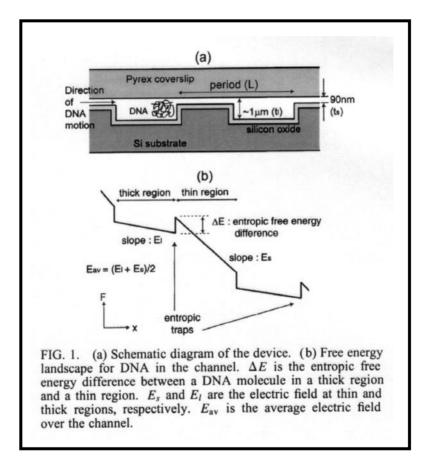


P. O. Vacaro, et al., Appl. Phys. Lett., 78, 2852 (2001).

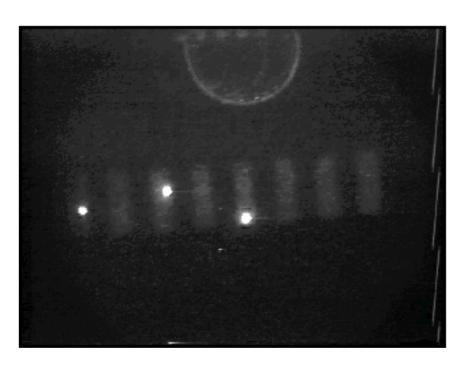
Microfluidic Channels

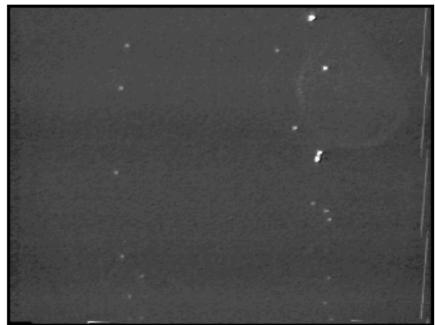


H. G. Craighead, Science, 290, 1532 (2000).

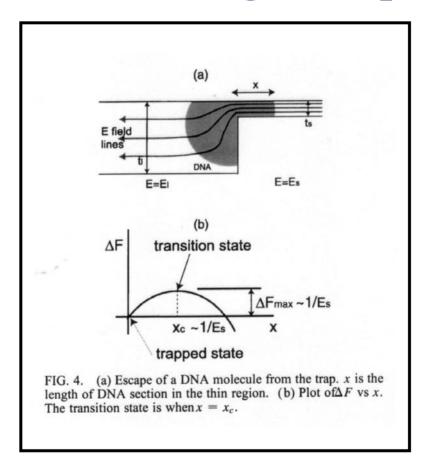


J. Han, et al., Phys. Rev. Lett., 83, 1688 (1999).

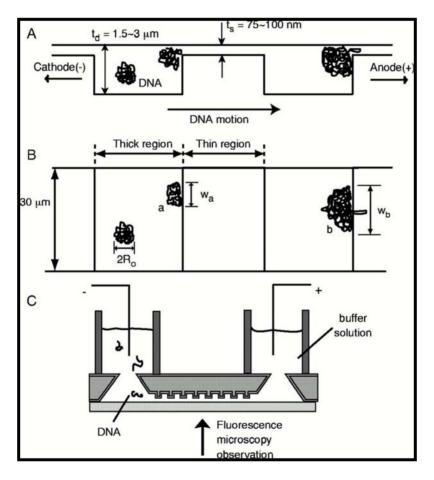




J. Han and H. G. Craighead, Science, 288, 1026 (2000).



J. Han, et al., Phys. Rev. Lett., 83, 1688 (1999).



J. Han and H. G. Craighead, Science, 288, 1026 (2000).